

L Number	Hits	Search Text	DB	Time stamp
3	19	(plasma near processing) and (vacuum near vessel) and (antenna and faraday adj shield)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/10/14 18:29
4	370	voltage near 500v	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/10/14 18:51
5	15115	plasma near processing	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/10/14 18:52
6	357	antenna and faraday adj shield	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/10/14 18:53
7	1	faraday adj shield near 500V	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/10/14 18:53